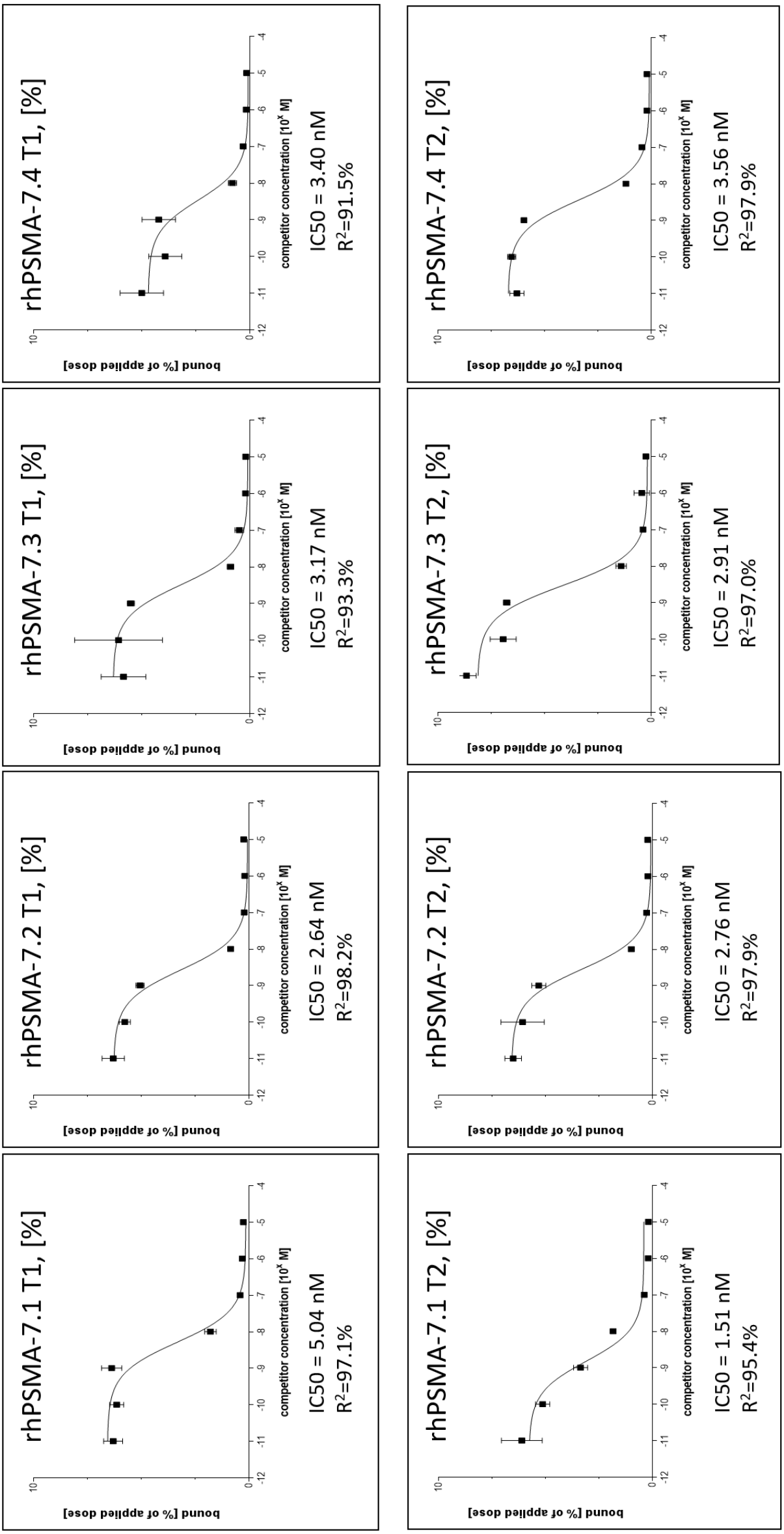

rhPSMA-7.4 T1, [%]
IC50 = 3.40 nM
R²=91.5%
rhPSMA-7.3 T1, [%]
IC50 = 3.17 nM
R²=93.3%
rhPSMA-7.2 T1, [%]
IC50 = 2.64 nM
R²=98.2%
rhPSMA-7.1 T1, [%]
IC50 = 5.04 nM
R²=97.1%
rhPSMA-7.4 T2, [%]
IC50 = 3.56 nM
R²=97.9%
rhPSMA-7.3 T2, [%]
IC50 = 2.91 nM
R²=97.0%
rhPSMA-7.2 T2, [%]
IC50 = 2.76 nM
R²=97.9%
rhPSMA-7.1 T2, [%]
IC50 = 1.51 nM
R²=95.4%
bound [% of applied dose]
competitor concentration [10^x M]

Fig. 6b

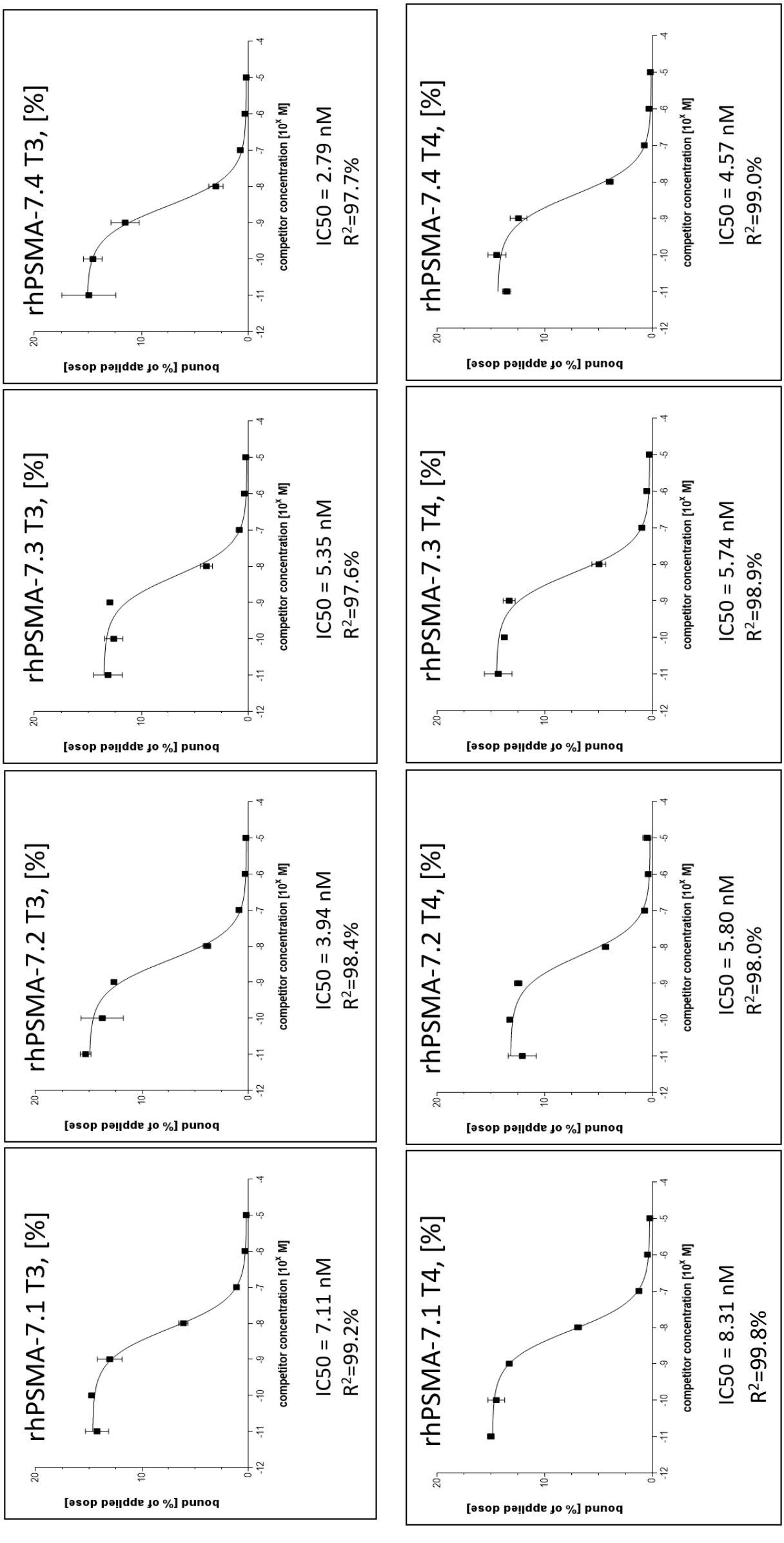
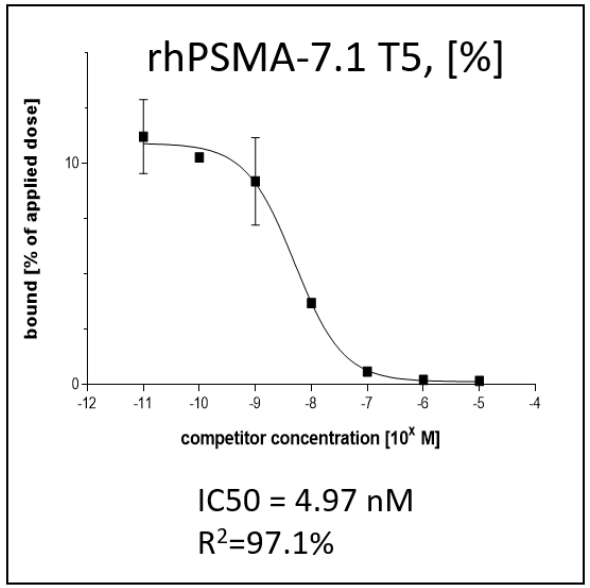
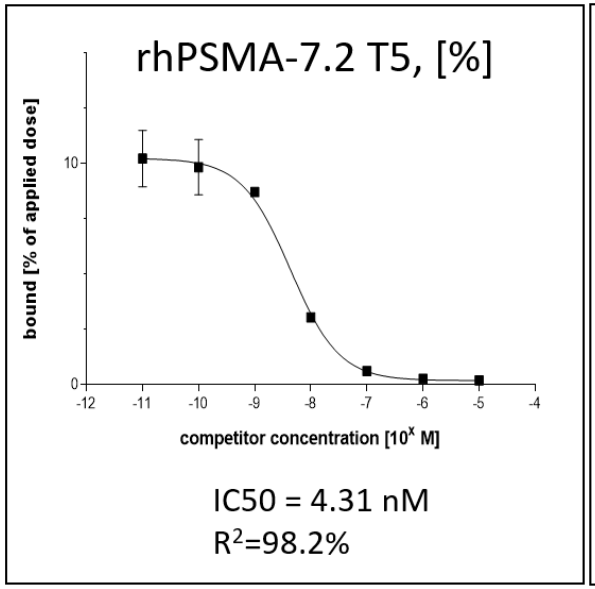
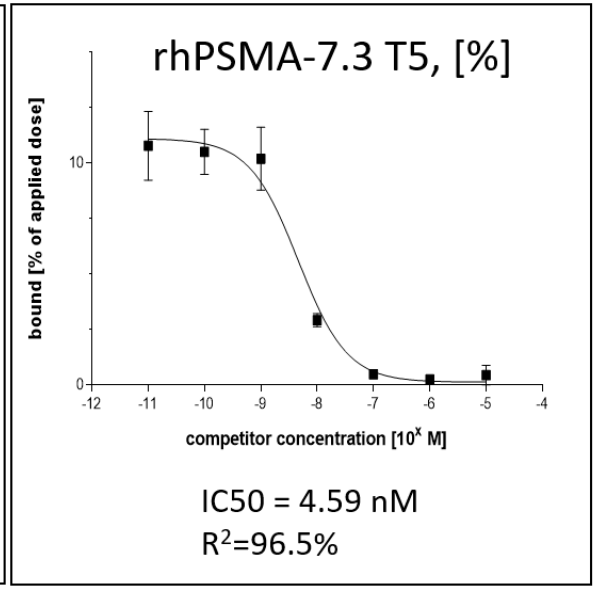
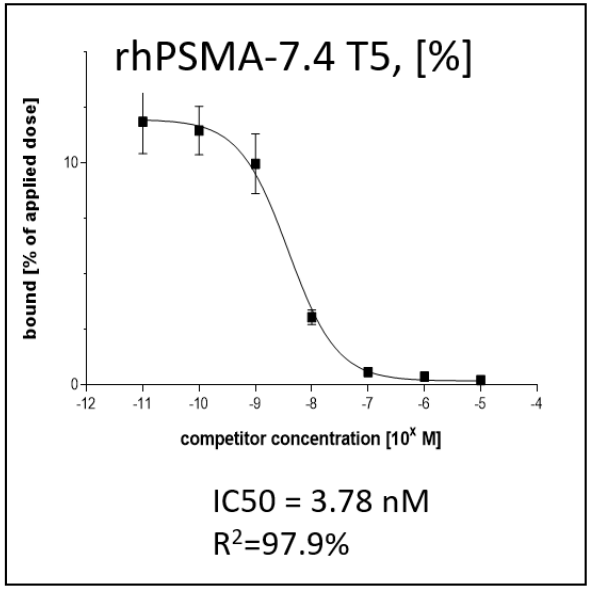


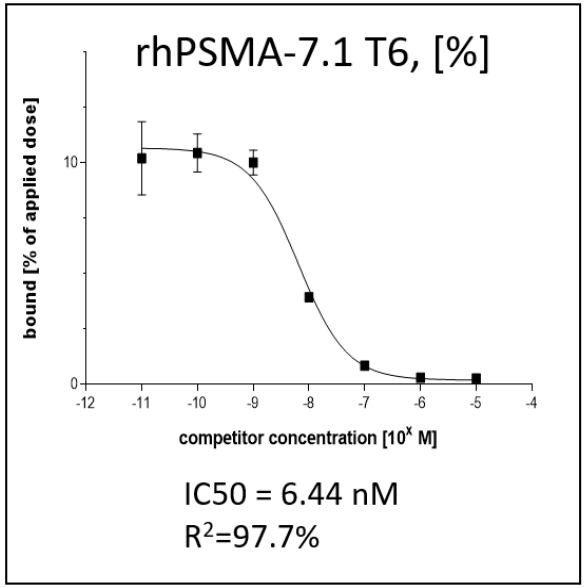
Fig. 6b (continued)

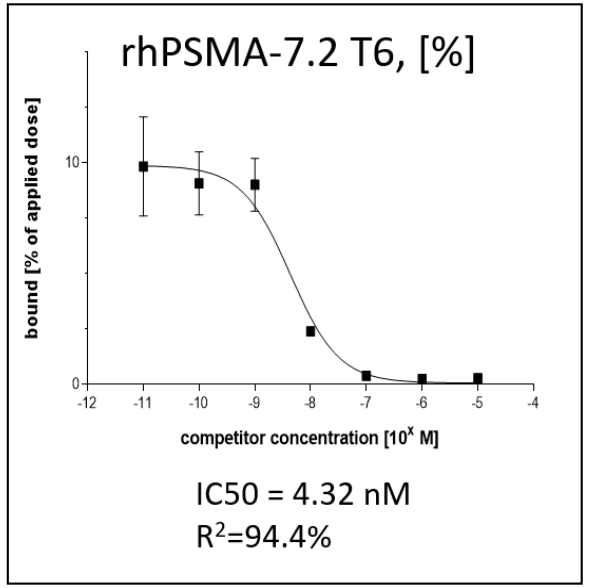












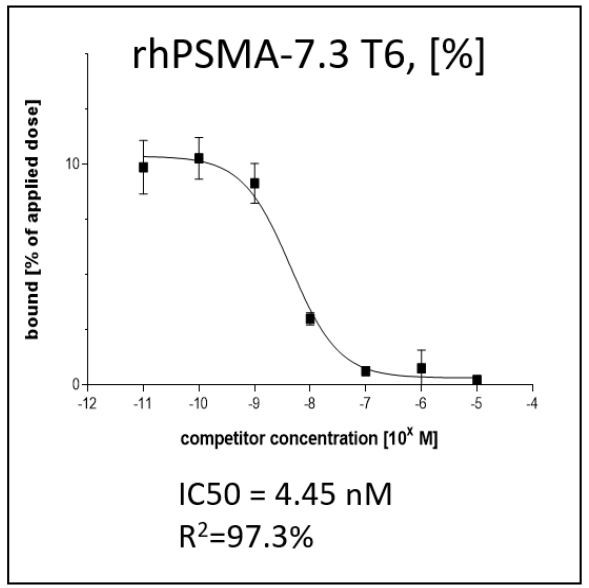


Fig. 6b (continued)